## GOVERNMENT OF INDIA MINISTRY OF DEFENCE DEPARTMENT OF DEFENCE PRODUCTION LOK SABHA UNSTARRED QUESTION NO.593 TO BE ANSWERED ON 5<sup>th</sup> February, 2020

## INTELLECTUAL PROPERTY RIGHTS IN DEFENCE

## 593. SHRI RAJESHBHAI CHUDASAMA:

Will the Minister of DEFENCE j{kk ea=h be pleased to state:

(a) whether the Government has taken any measures to promote self-reliance in Intellectual Property Rights (IPRs) in Defence;

(b) if so, the details thereof;

(c) the impact of such measures on cost savings; and

(d) the challenges faced by the Defence sector in attracting private and public sector entities for IPRs?

## A N S W E R

MINISTER OF STATE IN THE MINISTRY OF DEFENCE रक्षा राज्य मंत्री (SHRI SHRIPAD NAIK)

(श्री श्रीपाद नाईक)

(a) to (d): In 2018, Ministry of Defence, Department of Defence Production has launched a programme 'Mission Raksha Gyan Shakti (MRGS)' to promote self-reliance and have an enabling framework for creation of Intellectual Property (IP) and management of Intellectual Property Rights (IPRs) in Indian Defence sector. Since the launch of programme MRGS, a total of 1084 IP applications have been filed by the personnel of Defence Public Sector Undertakings (DPSUs)/Ordnance Factories (OFs). A major IPR

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Awareness Program has been launched and a total of 17938 personnel have been trained till 31 December, 2019. A nodal Intellectual Property Facilitation Cell (IPFC) has been set up under Directorate General of Quality Assurance to create awareness about IPRs. A comprehensive policy on creation of IP and Management of IPRs in DPSUs and OFs has been promulgated in November, 2019. Innovative research in DPSUs and Ordnance Factories has enabled the development of certain materials, components/assemblies/sub-assemblies that result in performance upgradation of existing systems/platforms and simultaneously reducing India's dependence on imports. Some of the challenges faced in attracting private and public sector entities for IPRs is the risk of leakage of classified information regarding defence technology due to mandatory disclosures associated with IPR filing and for combating IPR infringement.

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